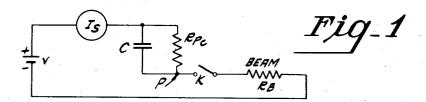
### Oct. 13, 1959

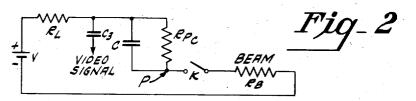
P. K. WEIMER PICKUP TUBE AND TARGET THEREFOR 2,908,835

Filed Oct. 4, 1954

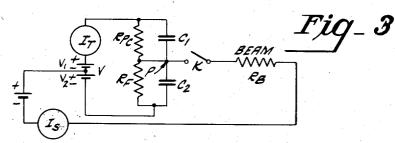
4 Sheets-Sheet 1



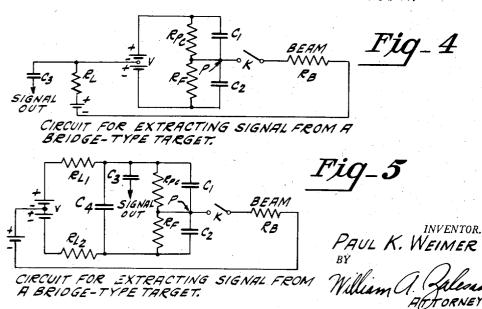
EQUIVALENT CIRCUIT OF A CONVENTIONAL SERIES-TYPE TARGET.



CIRCUIT FOR EXTRACTING THE SIGNAL CURRENT FROM A SERIES-TYPE TARGET.



EQUIVALENT CIRCUIT OF A BRIDGE TYPE TARGET.



### Oct. 13, 1959

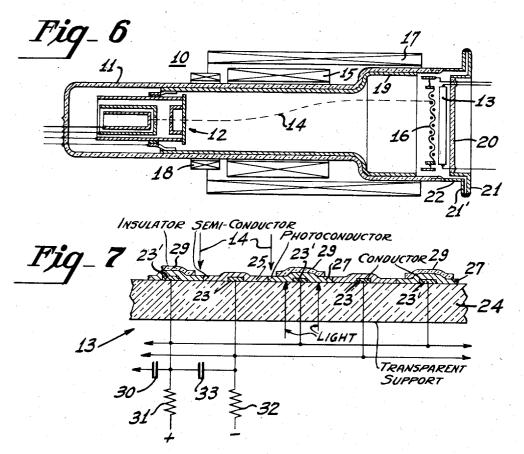
### P. K. WEIMER

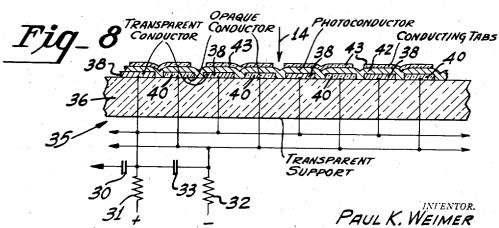
PICKUP TUBE AND TARGET THEREFOR

2,908,835

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4 Sheets-Sheet 2.





BY William a. Zalezak

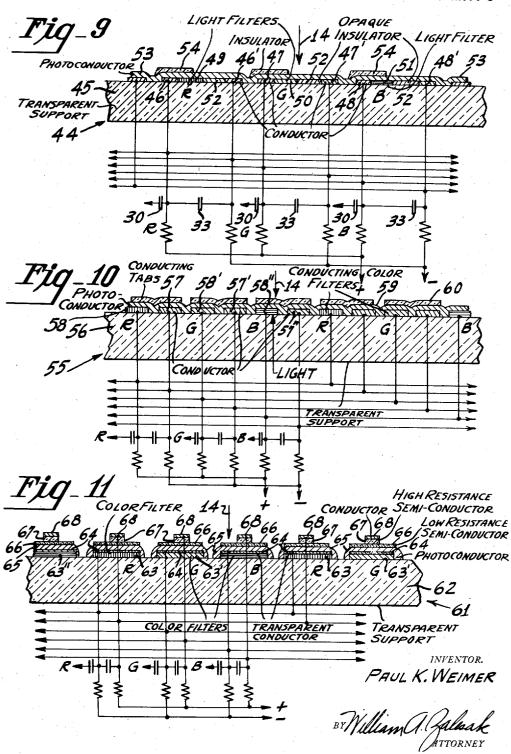
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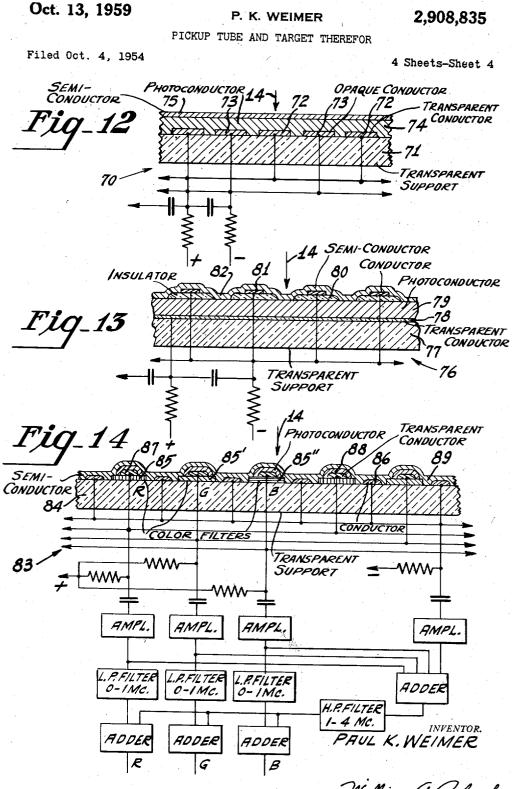
P. K. WEIMER

2,908,835

FICKUP TUBE AND TARGET THEREFOR Filed Oct. 4, 1954

4 Sheets-Sheet 3





BY William a. Jalenak

# United States Patent Office

### 2,908,835 Patented Oct. 13, 1959

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#### 2,908,835

#### PICKUP TUBE AND TARGET THEREFOR

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Application October 4, 1954, Serial No. 459,971

19 Claims. (Cl. 313-65)

This invention relates to television camera tubes and 15 particularly to improved television camera, or pickup, tubes having a novel target structure.

Conventional television camera tubes of the Vidicon type normally consist of an elongated envelope enclosing an electron gun in one end of the envelope. In the other 20 end of the envelope is provided a transparent electrode, which is referred to as a signal plate. On the transparent electrode there is deposited a thin layer of photoconductive material. During operation, an electron beam from the electron gun scans the photoconductor to establish 25 a charge thereon. When exposed to light, electron flow occurs between the two faces of the target through the photoconductive layer at the illuminated areas in accordance with the light intensity. This action produces a signal which can be used to transmit the scene picked up. 30 While this arrangement makes a fairly simple target for television camera tubes, certain improvements result by using target structures made in accordance with this invention.

In the conventional television camera tubes which uti- 35 lize a target including a photoconductive material, there is a limitation upon the materials which may be used as the photoconductor due to a requirement that the photoconductor be a material having a relatively high volume resistivity. This requirement occurs due to the fact that, 40 when using the standard methods of operating camera tubes, the charge released by the photoconductor being exposed to light must be stored for the period of time occurring between successive scans by the electron beam. Since the scanning period is 1/30 of a second, the volume resistivity of the photoconductor must be high enough to store charges for this period of time. The lower limit on the volume resistivity of the photoconductive materials which can be used in conventional targets is approximately 1011 ohm-centimeters. Several known photocon- 50 ductive materials have extremely high sensitivities but have resistivities that are lower than the 1011 ohm-centimeters requirement and thus cannot be used in conventional target structure. Since these highly sensitive materials cannot be used, prior to this time, a compromise 55 has been made between a lower sensitivity and a higher resistivity in selecting a photoconductive material.

Furthermore, when using conventional target structures, a storage time as long as  $\frac{1}{30}$  of a second has certain disadvantages. As an example, in certain types of television transmission, it is often desirable to transmit pictures of rapidly moving objects. When the storage time is  $\frac{1}{30}$  of a second blurred images occur in attempting to televise these rapidly moving objects.

Still further, in tubes utilizing conventional target structures and when utilizing a low velocity electron beam, the capacity of the target, i.e. the capacity between the signal plate and the photoconductor, must be kept below several thousand micro-micro-farads for the beam to discharge the target in one scan. When objectionable capacity lag occurs, i.e. capacity lag longer than the  $\frac{1}{30}$  of a second scanning period, signals from one frame are car2

ried over into the next frame resulting in a poor reproduction of the scene. In other words, objectionable capacity lag occurs when the target is not discharged by one scan of the electron beam. In order to keep the capacity small in prior art targets, the photoconductor must be made thicker than would otherwise be desirable for maximum sensitivity.

It is therefore an object of this invention to provide a novel target structure for television camera tubes which permits the use of photoconductive materials having relatively low volume resistivities but which nevertheless provides the high sensitivity required in tubes of this type. It is a further object of this invention to provide a novel target structure for television camera tubes which 15 eliminates capacity lag effects and thus permits more effective transmission of rapidly moving objects.

A further object of this invention is to provide a new and more sensitive target for television camera tubes wherein it is not necessary for the electron beam to completely discharge the target in a single scan.

A still further object of this invention is to provide an improved camera tube having improved sensitivity.

These and other objects, applicable to television camera tubes of the monochrome type or the tri-color type, are accomplished in accordance with this invention by providing a television camera tube having a novel and an improved photoconductive type of target. In the various embodiments of the target shown and described, the photoconductive material functions in conjunction with a plurality of spaced apart signal output electrodes in a manner such that the resistance of the photoconductor forms one arm of a bridge while a fixed resistance forms a second arm of a bridge resulting in a bridge type equivalent circuit. The bridge type target may be incorporated into targets having the conventional transverse electron flow or in targets having lateral electron flow which will be described below.

The novel features which are believed to be characteristic of this invention are set forth with particularity in the appended claims. The invention itself will best be understood by reference to the following description taken in connection with the accompanying four sheets of drawings and in which:

Fig. 1 is an equivalent circuit diagram of a conventional series type target;

Fig. 2 is the equivalent circuit diagram of Fig. 1 modified to illustrate a method of extracting the signal from the circuit of Fig. 1;

Fig. 3 is an equivalent circuit diagram of a bridge type target made in accordance with this invention;

Figs. 4 and 5 are equivalent circuit diagrams of Fig. 3 modified to illustrate methods of extracting the signal from the circuit of Fig. 3;

Fig. 6 is a longitudinal sectional view of a camera tube utilizing a target in accordance with this invention;

Fig. 7 is an enlarged fragmentary sectional view of a target of the lateral current flow bridge-type in accordance with this invention for use in a monochrome type pickup tube as shown in Fig. 6;

Fig. 8 is an enlarged fragmentary sectional view of a modification of a target of the transverse flow bridge type in accordance with this invention for use in a monochrome camera tube such as the tube shown in Fig. 6;

Figs. 9 through 11 inclusive are enlarged fragmentary sectional views of modifications of target structures in accordance with this invention for use in a tri-color pickup tube such as the tube shown in Fig. 6;

Figs. 12 and 13 are enlarged fragmentary sectional views of modifications of target structures in accordance with this invention for use in a monochrome type of camera tube such as the tube shown in Fig. 6; and,

Fig. 14 is an enlarged fragmentary sectional view of a

modification of a target structure in accordance with this invention for use in a tri-color type of camera tube such as the tube shown in Fig. 6.

Referring to Fig. 6 there is shown a pickup or camera, tube 10 comprising a vacuum tight envelope 11 having 5 an electron gun 12 mounted in one end thereof. The electrodes of the electron gun 12 include the usual cathode, control electrode, and one or more accelerating anodes which are connected to lead-in means in the wellknown manner. An electron beam 14 from the gun 12 10 is directed upon a target 13 at the other end portion of envelope 11. Means are provided for focusing the electron beam 14, and scanning the beam 14 over target 13 to form a raster. These means may include a focus coil 17, a deflection yoke 15, and an alignment coil 18 as 15 shown. An electrode 16 is positioned adjacent to the target 13 and, in operation, together with focus coil 17 cooperates to insure that the electron beam 14 in its final approach to the surface of target 13 is normal thereto. A final accelerating electrode 19 may take the form of a 20 conductive coating on the interior of envelope 11. Fingers mounted on the gun 12, but insulated therefrom, serve to connect conductive coating 19 to one of the lead-in pins.

Target 13 is conventionally supported adjacent to a 25 transparent window 20 and has terminal pins sealed therethrough as shown. The transparent window 20 is supported in the end of the envelope 11 by means of a hollow metallic member 21 which is in turn welded to a similar hollow metallic member 21' that is sealed to the 30 body portion of envelope 11.

The various elements of camera tube 10 that are referred to above are conventional. In a conventional tube the target 13 comprises a transparent conductive electrode, or signal plate supported adjacent to the window 20, and a photoconductive layer on the signal plate. The elements of a target electrode that are normally included in a conventional tube are not shown in detail.

Referring now to Fig. 1 there is shown schematically an equivalent circuit of a conventional photoconductive pickup tube. This circuit is shown for the purpose of more clearly explaining applicant's invention and forms no part of this invention. In this circuit  $R_{PC}$  and C represent the elemental photoconductive resistance and capacitance respectively, which exists between the scanned surface of the photoconductive layer and the signal plate. The light sensitive target element is connected at point P, i.e. where the beam strikes the target, in series with a voltage supply V and an electron beam through a switch K which is normally open but which is closed momentarily each  $\frac{1}{30}$  of a second for a period of

# $\frac{1}{30}$ $\frac{1}{N}$

seconds, where N is the total number of picture elements. The beam resistance  $R_B$  has a value of approximately 10 megohms for low velocity scanning.

Two conditions must be satisfied for charge storage type of operation of conventional photoconductive pickup tube targets, ie. those of a type schematically shown in Fig. 1. These conditions are: (1) the time constant for storage purposes, which is given by the product of  $R_{PC}$ times C, must exceed  $\frac{1}{30}$  of a second for frame storage, or  $\frac{1}{35000}$  of a second for line storage; and (2) the time constant for discharge purposes, which is given by  $R_B$  65 times C, must be less than

# $\frac{1}{30 N}$

seconds in order for the beam to discharge the target in 70 one scan.

These two conditions can be expressed in terms of the total resistance and the capacity of the entire target. When so expressed, for frame storage, condition (1) above is  $R_{PCT}C_T$  must be greater than  $\frac{1}{20}$  of a second. 75

While condition (2) above, when so expressed is  $R_B.C_T$  must be less than  $\frac{1}{200}$  of a second.

where:  $R_{PCT}$  is the parallel resistance of the entire scanned surface.

Condition (1) above establishes a lower limit on the volume resistivity of the photoconductor which can be used in a conventional tube. For conventional targets, operating with transverse flow and frame storage, the volume resistivity must be  $10^{11}$  ohm-centimeters or greater. Lateral flow targets, i.e. where current flow is substantially parallel to the target, permit the resistivity to be as low as  $10^9$  ohm-centimeters. For line storage these values are each reduced by a factor of 500.

Condition (2) above establishes an upper limit of several thousand micro-micro-farads on the total capacity of the target in a conventional tube for a beam resistance of 10 megohms. A practical lower limit of the capacity is set by the amount of stored charge required to give a signal sufficiently large for an adequate signal-to-noise ratio.

The signal current  $I_{\rm S}$ , which flows in the series circuit shown schematically in Fig. 1, could be measured and utilized in two ways. One method consists of inserting a load resistor  $R_{\rm L}$  in series with the signal plate and coupling the resulting voltage fluctuation into an amplifier as shown in Fig. 2.

Alternatively, the load resistor may be omitted and the signal current fluctuation may be measured indirectly by collecting and amplifying the fraction of the electron beam which fails to be deposited on the target. Both of these methods of extracting a signal are conventional and form no part of the present invention, and are shown merely to illustrate the principles of this invention.

In principle, conventional series type photoconductive pickup tube targets wherein the photoconductor has a resistivity which is too low for charge storage operation can be operable. However, such targets have never performed satisfactorily in the past. The reason for this is that the high dark current places severe demands on the uniformity on the secondary emission on the conductivity of the target. Thus, from a practical standpoint, charge storage for at least line time and preferably for frame time is necessary. The present invention permits satisfactory operation without requiring charge storage.

45 Referring now to Fig. 3 there is shown an equivalent circuit, for a picture element, of a tube, such as tube 10 shown in Fig. 6, utilizing a bridge type target, such as the target shown in Fig. 7, and in accordance with this invention. In this instance, the photoconductive resist-

ance RPC forms one arm of a potentiometer bridge cir-50 cuit, instead of the series connected circuit of Fig. 1. The other arm of the bridge comprises a fixed resistance  $R_F$ . A potential difference  $V_1 + V_2$  is applied across the elemental bridge. The scanning beam makes contact, at point P, with the target by closing switch K at the junc-55 tion of the light-sensitive resistance  $R_{PC}$  and the fixed re-The resistance and voltages are so chosen sistance R<sub>F</sub>. that, in the absence of light, the bridge balances at the dark potential required by the scanning beam. For low velocity scanning the dark potential may equal the gun cath-60 ode potential. When light falls on the target, the variable resistance  $R_{PC}$  decreases and the point P assumes a different potential, which depends upon the new value of the ratio of  $R_{PC}$  to  $R_{F}$ . For low velocity scanning the maximum light potential may be several volts above the potential of the gun cathode. The fraction of the beam deposited at point P, which depends upon the potential of point P, provides the signal current. As will be explained hereinafter both the fixed resistance  $R_{\rm F}$  and photoconductive resistance  $R_{\rm PC}$  may be obtained from the photoconductive material by shielding portions of the photoconductor from the light to result in a fixed resistance. Alternatively, the fixed resistance can be obtained from a non-photoconductive semi-conductor.

An important feature of the bridge type targets in

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accordance with this invention, is that the conditions (1) and (2) which have been set forth above, no longer have the same significance. The charge storage time constant of the bridge type target is given by the expression

$$\frac{R_{PC}R_{F}}{R_{PC}+R_{F}} \cdot (C_{1}+C_{2})$$

A significant difference of the bridge type target, as compared to conventional targets, is that satisfactory output 10 signals can be generated using photoconductors in which this time constant is considerably less than that necessary for storage purposes in conventional targets. For a very fast photoconductor, i.e. one having a time response much less than  $\frac{1}{30}$  of a second, this means a slight 15 reduction in sensitivity but a great improvement in the definition obtainable when televising rapidly moving objects. If the photoconductor has a time response of approximately  $\frac{1}{30}$  of a second, a low resistivity will not limit the sensitivity of the target nor will it have any 20effect on the sharpening of the resolution of moving objects. The lower limit on the resistivity of a photoconductor in a bridge type target in accordance with this invention, is probably established by the current carrying capabilities of the target structure, and by the 25 sensitivity of the photoconductor which must be more sensitive for lower resistivities in order to provide adequate potential variations to effectively modulate the beam. The dark current through the bridge circuit does not appear in the output signal and does not have to be 30 carried by the beam.

The condition, set forth above, for discharge purposes to avoid lag in conventional tubes, is not necessary in tubes utilizing bridge type targets in accordance with this invention, provided the frame storage time constant is 35 less than  $\frac{1}{30}$  of a second. Under these conditions, the target is self-discharging when the light is removed and does not require the beam for discharge. A consequence of this feature is that the capacity of the target can be larger than would be permissible if it were necessary 40 to satisfy the the second condition set forth above. Thus, the photoconductor can be made thinner than is possible when utilizing conventional series type targets. The thin photoconductor makes possible improved sensitivity and, when desired, larger target areas. 45

Referring now to Fig. 4 there is shown a method of inserting load resistors in the equivalent bridge type circuit shown in Fig. 3. The voltage fluctuations produced by the load resistance R<sub>L</sub> are coupled to a video amplifier (not shown) by means of coupling capacitor C3. An 50alternative method is shown in Fig. 5. The load resisotrs  $R_{L_1}$  and  $R_{L_2}$  are connected to the opposite branches of the bridge circuit. The external capacitor C4 may be inserted to insure that the complete video signal is obtained. In practice capacitor  $C_4$  may be unnecessary because its function is accomplished by the internal series capacity  $C_1$  and  $C_2$ . The total video signal is coupled to an amplifier (not shown) through the coupling capacitor  $C_3$ . As an alternative of the methods of obtaining the output signal from a tube having a bridge type target, the signal may be obtained from the return beam which is collected and directed into an electron multiplier. In this case the load resistors  $R_{L_1}$  and  $R_{L_2}$ may be omitted. It should be understood that in the equivalent circuit diagrams of Figs. 3-5 that the light 65 sensitive resistance may be the negative arm of the bridge, rather than the positive arm of the bridge as shown, in which case an inverted polarity signal results. Also, the mean potential of the bridge may be raised considerably above gun cathode potential for high velocity scanning.

The tolerance of high capacity and high dark current in the bridge type target in accordance with this invention makes this type of target especially suitable for use with P-N junctions as the light sensitive resistance. Such and good sensitivity, but are difficult to make for the conventional series type targets because of their high dark current and high capacity per unit of target area. Referring now to Figs. 6 and 7 there is shown a new

and improved pickup tube 10 in accordance with this invention. Certain elements of tube 10, which are conventional, have been previously described. However, in accordance with this invention a target 13, which is shown more clearly in Fig. 7, comprises a support, or backing, plate 24 which may be of a material such as glass. The support plate 24 may be omitted when desired and the balance of the target 13 may be supported directly on the transparent window 20, shown in Fig. 6, which then also serves the same function as support plate 24. There is provided on the surface of the support plate 24, which is normally scanned by the electron beam 14, a plurality of spaced apart conducting signal strips 23 and 23'. In contact with, and extending on each side of each of the signal strips 23', is a strip of photoconductive material 27. In contact with, and extending on each side of signal strip 23 is a non-photoconductive strip of semi-conducting material 25. The semi-conductive material 25 extends along the support member 24 and is in contact along its edges with the photoconductor strips 27. On the exposed surface of photoconductive material 27, i.e. the surface upon which beam 14 lands, there is provided a plurality of strips of insulating material 29. As can be seen from the drawing each of the strips of insulating material 29 is adjacent one of the signal strips 23'. It should be understood that the insulating strips 29 are optional and may be omitted if the benefits of the coplanar grid effect are desired.

Connected to each of the plurality of signal strips 23' is a resistor 31 ( $R_{L_1}$  of Fig. 5). Connected to each of the plurality of signal strips 23 is a resistor-capacitor circuit which includes a load resistor 32 ( $R_{L_2}$  of Fig. 5) and a capacitor 33 ( $C_4$  of Fig. 5), the latter of which is connected to the junction between resistor 31 and capacitor 30. As shown in the drawings, the other end of the resistors 31 is connected to the positive side of a potential source while the other end of resistor 32 is connected to the negative side of a potential source. The other side of capacitor 30 is connected with the first amplifier stage (not shown) after the camera tube.

In the embodiment shown in Fig. 7 the fixed resistance (R<sub>F</sub> of Fig. 3) is obtained by means of the resistance of the semi-conductor 25, while the variable resistance  $(R_{PC} \text{ of Fig. 3})$  of the bridge comprises the photoconductor 27 which is exposed to light, i.e. the areas adjacent the signal strips 23'.

As shown in the drawings, the lead-ins for the signal strips 23 and 23' extend through the support plate 24. This method of illustration is utilized merely for ease of illustrating the appropriate connections. In actual practice, the ends of the conducting strips 23 and 23' would be connected together inside the envelope 11 and each set would have a common lead extending through the walls of envelope 11.

The support plate 24 may be constructed of any transparent material such as glass, mica, or quartz, and may be of any thickness ranging from more than 1/8 inch down to less than one-thousandth of an inch. As an alternative to the materials mentioned for the support plate 24, the support plate may be made of a thin transparent membrane such as aluminum oxide stretched on a rigid frame (not shown). Still further, the transparent window 20 may serve as the support plate. Alternatively, the photoconductor sheet or the signal strips may be made sufficiently rigid that the entire target structure can be self-supporting inside the tube without contact to any support plate. A still different method of supporting the target, which is not illustrated, is to use a thin sheet of semi-conducting material or a support plate on the beam side of the target. A thin sheet of lime glass about 5 photosensitive barriers have intrinsically fast response 75 microns thick has the proper resistivity to conduct the

signal current through the glass without loss of resolution by lateral leakage.

The signal strips 23 and 23' may be composed of some highly conductive material such as aluminum, gold, or 5 tin oxide, and may be of a width ranging from substantially 1/2 mil. to several mils. The number of signal strips 23 and 23' for any given target 13 will be determined by the definition required in the picture to be reproduced, and generally should be from about 500 to several thousand for a high quality picture. The signal strips 10 23 and 23' may be thin strips of conducting material approximately 100 to 1000 Angstrom units thick applied to the support plate 24 by well-known means such as evaporation, or they may be metallic strips of metal heavy 15 enough to support the entire target.

The photoconductive material 27 may be any of the well-known highly sensitive photoconductive materials such as antimony sulfide, cadmium selenide, cadmium sulfide, or selenium. The photoconductive material 27 may be of a thickness within the range of approximately 1000 20 Angstrom units thick to several microns. The resistivity of the photoconductive material 27 may vary over a wide The range and may be as low as 10<sup>6</sup> ohm-centimeters. photoconductive layer may be deposited by evaporation, crystallization, chemical reaction, or other well-known 25 means.

The insulating strips 29 may be any of the well-known goods insulators such as zinc sulfide, magnesium fluoride or aluminum oxide. The thickness of insulator strips 29 should be of a thickness that is sufficient to insulate the 30 junction between a signal strip 23' and the photoconductor sheet 27 from bombardment by the electron beam 14. An insulator of approximately 1 micron in thickness is usually sufficient.

The semi-conductive strips 25 may be any semi-con-  $^{35}$ ductive material which is not a photoconductor. One example of such material is germanium. The thickness and the resistivity of the semi-conductor should be so chosen so that with reasonable applied voltages the exposed areas of photoconductor 27 will balance to ground 40 in the dark, and further, that leakage along the semiconductor 25, parallel to the strips 23, will not be great enough to deteriorate resolution.

The target 13 may be oriented in any desired manner within the tube 10. For example, the signal strips 23 45and 23' may be arranged parallel or perpendicular to the direction of scan. The pickup tube 10 may be operated in several ways and both low and high velocity operation of the electron beam is suitable.

During operation of the tube 10, potentials are applied 50 to the various electrodes to form an electron beam 14 which is directed toward the target 13. The electron beam 14 is scanned across the surface of target 13 in a rectangular raster by magnetic deflecting fields produced by the deflecting yoke 15. The deflection yoke 15 nor-55mally consists of two pairs of magnetic coils with the coils of each pair connected in series and positioned on opposite sides of the envelope 11. The pairs of coils are arranged so that the field produced by one pair is substantially normal to the field produced by the other pair of coils. Each pair of coils is connected to appropriate sources of voltages (not shown) to produce both horizontal deflection and vertical deflection of the electron beam 14 in a conventional manner to provide a rectangular scansion raster. The means for producing this type 65 of scansion raster is well-known and is not considered further as it is not a part of this invention.

Electrons from the beam 14 will be deposited upon the exposed areas of the photoconductor sheet 27, and upon the strips of insulating material 29, until the po- 70 tential of the insulating strips is driven substantially to the potential of the cathode of the electron gun 12. The electron beam 14 lands on the target 13 and the charge deposited is determined by the potential existing on the storage area of the photoconductor 27. These charged 75 comprising a coupling capacitor 30 and a load resistor 31,

storage areas comprise the portion of the photoconductor sheet that is between an end of an insulating strip 29 and an adjacent insulating strip 25. The target 13 has two separate resistance elements. One of these resistance elements is the resistance of the photoconductor which is beneath an insulator strip 29. The resistance of the photoconductor which is underneath an insulating strip 29 is the variable resistance which is described in connection with Figs. 3 through 5 as  $R_{PC}$ . The other resistance of target 13 is the resistance of the semi-conductor 25. The resistance of the areas of semi-conductor 25 is the fixed resistance which is described in connection with Figs. 3 through 5 as  $R_F$ . When the elemental areas of the target 13 are not illuminated by a scene to be reproduced, the fixed and variable resistances are substantially equal. When an elemental area of the target 13 is illuminated, the variable resistance is decreased and the potential of an elemental area of the photoconductor rises a few volts. When the electron beam 14 scans over an elemental area which has a potential that is slightly positive, electrons are deposited in the storage areas of the photoconductor and a video signal is generated in the signal strips 23 and 23' by virtue of the target capacity existing between the strips and the storage area. This signal is coupled to the first tube of the video amplifier

(not shown) by means of the capacitors 30 and 33. As can be seen from Fig. 7, the capacity of the target 13 is a parallel combination of the capacity existing between the storage area and the adjacent signal strips 23 and 23'. This parallel combination is illustrated by capacitors C1 and  $C_2$  in the equivalent circuit of Figs. 3, 4 and 5. Since these capacitors are shunted by the variable, or photoconductor resistance  $R_{PC}$ , and by the fixed resistance  $R_{F}$ , the target capacity does not need to be discharged completely by a single scan of the beam 14 to avoid capacitive lag. In other words, when an image is removed from the target, the elemental storage areas return to zero or dark potential regardless of whether the elemental area is scanned or not simply by flow of current in the bridge formed by the fixed and the variable resistances.

There is no objectionable lag in target 13 if the RC time constant of the target is substantially less than the  $\frac{1}{30}$  of a second scanning period. Since the RC time constant is the product of the parallel combination of the fixed and the variable resistances and the parallel combination of the capacitors  $C_1$  and  $C_2$ , the  $\overline{R}C$  time constant may be varied by varying the resistivity and thickness of the photoconductor or by varying the spacing of the signal strips.

Although some photocurrent is wasted by leaking off of the charge from the elemental storage areas, through the fixed resistor, this loss of photocurrent is more than compensated for by the freedom given the tube designer in being able to operate with a target time constant that is less than  $\frac{1}{30}$  of a second. Due to the fact that it is possible to operate with an RC time constant of less than  $\frac{1}{30}$  of a second, photoconductive materials having lower volume resistivities may be utilized. In fact, volume resistivities of the photoconductor as low as 10<sup>6</sup> ohm-centimeters are usable. Furthermore, due to the fact that the storage time may be reduced below  $\frac{1}{30}$  of a second, the images of rapidly moving objects will be sharp discreet images.

Referring now to Fig. 8, there is shown a partial sectional view of a modification of this invention. The target 35 comprises a support plate 36 having on the beam side thereof, a plurality of spaced apart transparent conducting strips 38. On the surface of the support plate 36 and spaced in between each of the signal strips 38 is a strip of opaque conducting material 40. The plurality of transparent conducting strips 38 and the opaque conducting strips 40 function as the signal strips for the target 35. The strips of transparent conducting materials 38 are connected together and to an output circuit while the opaque conducting strips 40 are connected together and to a circuit comprising a coupling capacitor 33 and a load resistor 32 as was described above.

Covering the exposed areas of the opaque conducting strips 40, and the transparent conducting strips 38, is a 5 sheet of photoconductive material 42. Covering the exposed surfaces of the photoconductive material 42, over each pair of transparent signal strips 38 and opaque signal strips 40, is a plurality of short conducting tabs 43. The photocurrent through the bridge circuit of target 35 is substantially from the transparent signal strips 38 through the photoconductor to the conducting tab 43, then parallel to the surface along the tab to an area above an opaque strip, then through the photoconductor to the underlying opaque strip 40. This flow of current in the 15 photoconductor is substantially transverse to the target, whereas in Fig. 7 the photocurrent was substantially parallel to the target surface. The fixed resistance ( $R_F$  of Figs. 3 through 5) of the bridge is the resistance of the photoconductor 42 in the areas over the opaque strips 40 20 while the variable resistance  $(R_{PC} \text{ of Figs. 3 through 5})$ of the bridge is the resistance of the photoconductor in the illuminated areas.

The short conducting tabs 43 may be of any highly conductive material such as aluminum, gold, or tin oxide 25 and each covers a rectangular area of one to three thousandth of an inch on a side and may be of a thickness of 100 to 1000 Angstroms. The other materials shown in the modification of the target structure described in connection with Fig. 8 are similar to those set forth above 30 in connection with Fig. 7 and further description thereof is not deemed necessary at this time.

Referring now to Fig. 9 there is shown an enlarged fragmentary view of an embodiment of a target structure in accordance with this invention for use in a tri-color, 35 lateral flow, bridge type target. The target 44, which may be inserted in tube 10 shown in Fig. 6, comprises a support plate 45 having on the beam side thereof a plurality of spaced apart conducting signal strips 46 and 46' for the red, 47 and 47' for the green, and 48 and 48' for 40 the blue. Arranged on the surface of the support plate 45 between each respective pair of signal strips, and contiguous to one of the signal strips, is an insulating light filter strip 49 for the red, 50 for the green, and 51 for the blue. A plurality of opaque insulator strips 52 is 45 provided each of which is arranged in between a respective filter strip and conducting signal strip, and on the surface of the support plate 45. Covering the exposed surfaces of the signal strips, the color filter strips, the opaque insulating strips, and the remainder of the sup- 50 port sheet 45 is a thin sheet of photoconductive material 53. Covering each of the areas of photoconductive sheet 53 which is adjacent to a junction of a signal strip and a color filter strip, i.e., signal strip 46 and red filter 49, for example, is a protective insulator strip 54. 55

The materials utilized in target 44 may be similar to those that have been described heretofore as may be the size and numbers of each. The color filter strips 49, 50 and 51 are preferably made from some type of multilayer interference filter. These color filter strips are nor- 60 mally made of alternate layers of high index materials such as zinc sulfide, and low index materials such as magnesium fluoride with the thickness of each layer chosen to give the desired color. Other materials may 65 be utilized as the insulating material in the multi-layer interference filter such as kryolite and zinc selenide. It should be understood that other types of insulating color filter strips may also be utilized to derive the various color signals.

It should be noted that the insulating color filter strips 49, 50 and 51 are arranged in the conventional red, green, blue arrangement with signal strips 46 and 46', 47 and 47', and 48 and 48' respectively. The output connec-

there is provided coupling capacitors 30 and 33 for each of the individual colors. The video signal corresponding to each of the primary colors can be fed through these capacitors to separate color channels as is well-known in the art.

The opaque insulating strips 52 may be of any opaque insulating material such as black aluminum oxide, or an opaque metal covered with an insulating film. The insulating strips 52 may be substantially the same thickness and width as the conducting signal strips 46 and 46'.

During operation of the target 44, current flow is laterally through the photoconductor, i.e., similar to Fig. 7, and occurs only when a light signal to be reproduced is passed through a particular color filter 49, 50 or 51. As can be seen from Fig. 9, the resistance and capacitance of the target 44 is a parallel combination of resistances and capacitances as has been described hereinabove. In target 44, the fixed resistance ( $R_F$  of Figs. 3 through 5) of the target occurs in the areas of photoconductor directly over an opaque insulating strip 52; while the variable resistance ( $R_{PC}$  of Figs. 3 through 5) occurs in the area of photoconductor directly over a color filter strip 49, 50 or 51.

Referring now to Fig. 10, there is shown an enlarged fragmentary sectional view of a modification of a target structure of the transverse current flow, bridge type in accordance with this invention for use in a tri-color camera tube such as tube 10 shown in Fig. 6. The target 55 comprises a support plate 56 having on the beam side thereof a plurality of spaced apart opaque conducting strips 57, 57' and 57" for the red, green and blue signals respectively. Spaced intermediate each of the opaque conductive strips is a conducting color filter strip 58, 58' and 58" for the red, green, blue respectively. Covering the opaque signal strips, and the conducting filter strips, is a sheet of photoconductive material 59. Covering the areas of the photoconductive material 59 which are adjacent pairs of color filter strips and opaque conducting strips, as well as the photoconductor therebetween, is a plurality of short conducting tabs 60. Each of the color filter strips and its associated opaque conducting strip, is connected to a respective ouput circuit to provide an output signal in each of the primary colors as was described above.

The materials, and sizes, for the elements of target 55 are similar to those described in connection with Fig. 9. The conducting filters referred to here may be of the Fabry-Perot type consisting of two thin layers of metal separated by a thin transparent dielectric. Alternatively, the previously described insulating multi-layer interference filters may be used provided they are each covered with a different thin sheet of transparent conducting metal such as evaporated gold. The operational difference between target 55 and target 44 is that current flow occurs transversely through the target 55 which is similar to the current flow in the monochrome type target described in connection with Fig. 8.

Referring now to Fig. 11, there is shown an enlarged fragmentary sectional view of a modification of a target structure of the transverse current flow, bridge type in accordance with this invention. The target 61, which may be utilized in tube 10, comprises a support plate 62 having on the beam side thereof a plurality of spaced apart color filter strips 63, 63' and 63'' for the red, green and blue respectively. Covering each of the color filter strips 63, 63' and 63'' is a conducting strip of thin transparent metal 64. This layer may be omitted if the filter strips themselves are conducting as are the 70 Fabry-Perot type described for Fig. 10. A strip of photoconductive material 65 is deposited over each of the conducting signal strips and the adjacent portions of the exposed surface of the support plate 62. Individually covering each of the photoconductor strips 65 is a strip tions for the various signal strips are connected so that 75 of semiconducting material 66 which extends over the

photoconductor strips in the areas directly over each of the color filter strips 63, 63' and 63". The thin semiconductor 66 provides the storage area at which the beam makes contact to the target. A narrow semiconducting strip 67, of somewhat higher resistivity than 5 semi-conductor 66, is deposited over the thin semi-conductor 66. Over the top of the semi-conductor strip 67 a narrow conducting signal strip 68 is deposited. The potential difference across the bridge is applied to the upper and lower signal strips 68 and 64, respectively. 10 The applied potential may have the polarity shown or may have the reverse polarity.

Each of the conducting signal strips 64 is connected to an output circuit for the red, green and blue signals. Each of the conducting strips 68 is also connected to 15 the output circuit. The fixed resistance (R<sub>F</sub> of Figs 3 through 5) is obtained by the resistance of the semiconductor 67 while the variable resistance ( $R_{PC}$  of Figs. 3 through 5) is the resistance of the photoconductor strips 65 directly over a conducting color filter strip. The filter materials utilized in target 61 may be similar in size and material to those previously described. The thin semi-conducting strips 66 may be of a material such as germanium evaporated to a thickness of about a hundred Angstroms. The narrow semi-conductor strips 67 25 should have a relatively high resistivity and may be evaporated material such as lead oxide, or zinc oxide. As can be seen, Fig. 11 discloses a tri-color transverse flow bridge type target, the operation of which is similar to the operation of target 55 shown in Fig. 10. Alterna- 30 tively, the target of Fig. 11 may be operated with a high velocity beam.

Referring now to Fig. 12, there is shown an enlarged fragmentary sectional view of a monochrome, transverse flow, bridge type target utilizing a thin layer of 35 semi-conductor material in accordance with this invention. The target 70, which may be utilized in tube 10, comprises a glass support member 71 having a plurality of transparent conductive strips 72 spaced apart on the side of the support member 71 adjacent to the electron 40 Spaced in between each of the plurality of beam. transparent conducting strips 72 is an opaque conducting strip 73. Covering all of the plurality of transparent conducting strips 72, and all of the plurality of opaque conducting strips 73, is a continuous sheet of photo-45 conductor 74. Covering the exposed surface of the photoconductor 74 is a continuous sheet of semi-conducting material 75.

The materials utilized in target 70 may be substantially the same as those that have previously been de-50. scribed. With the semi-conducting material 75 being a material such as a thin layer of evaporated germanium. The operation of target 70 is such that the fixed resistance  $(R_F \text{ of Figs. 3 through 5})$  is obtained from the areas of photoconductor material 74 adjacent to an 55 opaque conducting strip 73; with the variable resistance  $(R_{PC} \text{ of Figs. 3 through 5})$  being obtained from the areas of photoconductor material 74 adjacent to the transparent conducting strips 72. The target 70 is substantially a transverse flow, bridge type target for use in the mono-60 chrome television as has been described. This structure is equivalent to that described in Fig. 8 except that the conducting tabs of Fig. 8 are replaced by a thin semiconducting sheet 75 having a resistivity chosen to give proper operation without loss of resolution. 65

Referring now to Fig. 13 there is shown an enlarged fragmentary sectional view of a modification of this invention comprising a target 76 including a support member 77 having on the beam side thereof a continuous layer of transparent conductive material 78. On the 70 exposed surface of the transparent conductive material 78 is provided a sheet of photoconductive material 79. Spaced apart on the exposed surface of the photoconductor material 79 is a plurality of insulating strips 80. Substantially centrally disposed upon each of the insu- 75 conductor material 88 would be approximately 1 micron.

lating strips 80 is a conducting strip 81. Covering each of the conducting strips 81, the exposed portions of the insulating strips 80, and the balance of the photoconductor sheet 79 is a continuous semi-conducting material 82.

In target 76, which may be utilized in tube 10, the lateral conductivity of the thin semi-conducting layer 82 is used as the fixed resistance ( $R_F$  of Figs. 3 through 5) of the bridge. The positive terminal is the underlying transparent conductive coating 78 on which is deposited the uniform layer of photoconductor 79. The negative terminal comprises the conducting strips 81 which are insulated from the underlying photoconductor by means of insulating strips 80. The semi-conducting

layer 82 connects the exposed areas of the photoconductor 79 to the conducting strips 81 thus providing the variable resistance ( $R_{PC}$  of Figs. 3 through 5) of the bridge. The reverse potential may be applied giving a video signal having opposite polarity, if desired. Also, the conducting strips 81 may be on the beam side of 20 semi-conductor 82 and the target 76 will bear substantially the same electrical properties as that shown. Due to the thinness of semi-conductive layer 82, the coplanar grid effect may be utilized in either instance.

The materials utilized in target 76 may be substantially the same as those that have previously been described with the continuous transparent conducting layer 78 being a material such as tin oxide although any suitable transparent conductive material may be utilized. The thickness and the resistivity of the semi-conducting layer 82 should be chosen so that, with reasonable applied voltages, the exposed areas of photoconductor 79 will balance to ground potential in the dark, and further, that leakage along the semi-conductor 82, parallel to the strips 81, will not be great enough to deteriorate resolution. Target 76 is a target of the transverse flow, bridge type, for use with monochrome television pickup tubes, the operation of which has previously been described.

Referring now to Fig. 14, there is shown an enlarged fragmentary sectional view of a tri-color, transverse flow, bridge type target structure in accordance with a modification of this invention. The target 83, which may be utilized in tube 10, comprises a support member 84 having a plurality of spaced apart color filter strips 85, 85' and 85" for the red, green and blue signals respectively. Spaced in between each of the color filter strips 85, 85' and 85" is a conducting strip 86 which may be either opaque or transparent. Supported substantially centrally on each of the color filter strips 85, 85' and 85" is a transparent conducting strip 87. Substantially covering each of the transparent conducting strips 87, and the balance of each of the color filter strips 85, 85' and 85", is a strip of photoconductive material 88. Substantially covering all of the conducting strips 86, all of the photoconductive strips 88, as well as the balance of each of the color filter strips 85, 85' and 85'' is a continuous semi-conducting layer 89.

As can be seen from the drawings, the negative terminal strips 86 fall between each of the color signal strips 85, 85' and 85" and serve as a shield between color strips in addition to their function as part of the bridge. Some monochrome signal will be picked up by the strips 86 and to obtain maximum signal to noise ratio in the mixed-high channel output from the camera, it may be desirable to add higher frequency components of this signal to the mixed-high signal obtained from the three sets of color strips 88.

A suitable photoconductor material for target 83 would be a photoconductor such as evaporated antimony sulfide or evaporated cadmium sulfide or selenide doped with one or more impurities to give a satisfactory red response and a volume resistivity of approximately 10<sup>9</sup> to 10<sup>11</sup> ohm-centimeters. Satisfactory thickness for the photo-

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A typical semi-conductor would be tin oxide having a resistivity of about 103 ohm-centimeters deposited in a layer less than 1 micron thick. Alternatively, a much thinner layer of evaporated germanium has been found to be suitable. The conducting strips may be gold or aluminum evaporated to a thickness of approximately .05 micron.

As can be seen from Fig. 14 there is provided a tricolor, transverse flow, bridge type target where in the variable resistance ( $R_{PC}$  of Figs. 3 through 5) is obtained 10 from the transverse flow of current through the photoconductor over the signal strips 87. The fixed resistance ( $R_F$  of Figs. 3 through 5) is obtained from the lateral conductivity of the semi-conductor between conducting strips 86 and the area over the photoconductor. 15

Although certain examples of geometry of photoconductive materials, semi-conductive materials, and color filter materials are shown, these are merely examples and it should be understood that it is within the contemplation of this invention to utilize strips or tabs of photo- 20 conductive material or semi-conductive material in the various embodiments shown. Also, since this invention contemplates tubes having bridge type targets utilizing either lateral flow, or transverse flow, for either the variable resistance or the fixed resistance, and certain exam- 25 stantially fixed electrical resistance, a second plurality of ples of these targets are shown, it should be understood that the invention should not be limited to these examples, but should include all such targets as come within the scope of the appended claims.

What is claimed is:

1. An electron discharge device including an envelope containing means for supplying a stream of electrons along a path, a target positioned in said path, said target comprising a transparent support member, a plurality of conducting signal strips supported by means of said sup-35 port member, alternate ones of said signal strips being electrically coupled to substantially fixed resistances in said target, intermediate ones of said signal strips being electrically coupled to variable resistances in said target, the junctions between a fixed resistance and a vari- 40 able resistance being directly exposed to said stream of electrons, and the magnitude of the resistance of said variable resistances varying in response to light directed onto said target.

2. An electron discharge device as in claim 1 further 45 comprising color filter means whereby the magnitude of said variable resistances varies in response to light of different colors.

3. An electron discharge device including an envelope containing means for supplying a stream of electrons along a path, a target positioned in said path, said target 50 comprising a transparent supporting member, a plurality of signal electrodes supported by means of said supporting member, photo-conductive means electrically coupled to said signal electrodes, a part of said photoconductive 55 means being shielded from light whereby the resistance of said part is substantially fixed, a second part of said photoconductive means being exposed to light whereby the resistance of said second part varies in response to light, and the junction between said parts being directly 60 exposed to said stream of electrons.

4. An electron discharge device as in claim 3 further comprising color filter means.

5. An electron discharge device comprising an envelope containing means for supplying a stream of electrons 65 along a path, a target positioned in said path, said target comprising a support member, a plurality of spaced apart conductive elements supported by said support member, a photoconductive means electrically coupled to the alternate of said conductive elements, semi-con- 70 ductive means electrically coupled to the intermediate of said conductive elements whereby the alternate of said conductive elements are electrically coupled to resistances that vary in response to light and the intermediate

substantially fixed resistances, and the junctions between said resistances that vary in response to light and said fixed resistances being exposed directly to said stream of electrons.

6. An electron discharge device including an envelope containing means for supplying a stream of electrons along a path, a target positioned in said path and including a transparent support member, a plurality of transparent conductive elements supported by means of said member, a plurality of opaque conductive elements supported by means of said member, and photoconductive means electrically coupled to said pluralities of conductive elements with the opaque conductive members shielding said photoconductive means from light whereby the resistance of said photoconductor adjacent to said opaque members is substantially fixed.

7. A television pickup tube comprising an electron gun for producing an electron beam, a target electrode including a supporting member, a plurality of spaced apart conductive elements supported by means of said member, photoconductive means electrically coupled to said conductive elements, a plurality of portions of said photoconductive means being shielded from light whereby said portions of said photoconductive means have a subportions of said photoconductive means being exposed to light whereby the resistance of said portions of said photoconductor varies in response to light, and a direct current path between said gun and a junction between 30 a fixed resistance and a variable resistance.

8. A television pickup tube as in claim 7 further comprising color filter means.

9. A television pickup tube as in claim 7 wherein each of said fixed resistances is in electrical parallel relation with one of said variable resistances.

10. A television pickup tube comprising an electron gun for producing an electron beam, a target in the path of said beam and comprising a support member, a plurality of spaced apart conductive elements supported by said support member, photoconductive means electrically coupled to the alternate of said conductive elements, semi-conductive means other than said photoconductive means electrically coupled to the intermediate of said conductive elements whereby the alternate of said conductive elements are electrically coupled to resistances that vary in response to light and the intermediate of said conductive elements are electrically coupled to substantially fixed resistances, and said semi-conductive means comprising a part of a direct current path between said gun and a junction of a fixed resistance and of a variable resistance.

11. A target as in claim 10 further comprising color filter means.

12. A target for a television camera tube comprising, a transparent support member, a first plurality of spaced apart conductive strips on one surface of said support member, a second plurality of spaced apart conductive strips on said one surface of said support member, each of said first plurality of strips being spaced in between a pair of said second plurality of strips, a photoconductor supported by means of said support member, means including each of said first plurality of strips for shielding portions of said photoconductor from light whereby the resistance of said portions is substantially fixed.

13. A target for a television camera tube comprising a transparent support member, a plurality of transparent conductive strips spaced apart on one surface of said support member, a plurality of opaque conductive strips spaced apart on said one surface of said support member and each spaced between an adjacent pair of said transparent strips, a continuous layer of photoconductive material covering said strips and the exposed areas of said support member therebetween, and a plurality of conductive tabs spaced apart on said photoconductive maof said conductive elements are electrically coupled to 75 terial, each of said tabs being disposed adjacent to one

of said transparent strips and an adjacent one of said opaque strips.

14. A television camera tube comprising an electron gun for producing an electron beam, a target in the path of said beam and comprising a transparent support mem-5 ber, a plurality of pairs of signal strips spaced apart on one surface of said member, a plurality of opaque in-sulator strips and a plurality of color filter strips supported on said one surface of said support member, one of said opaque insulator strips and one of said color 10 filter strips being supported between each pair of said signal strips, a continuous sheet of photoconductive material covering all of said strips and the portion of said support member exposed therebetween the portions of said photoconductive material over said opaque strips 15 comprising a substantially fixed resistance, the portions of said photoconductive material over said color filter strips comprising a variable resistance, the junctions between a fixed resistance and a variable resistance being directly exposed to said electron beam, and a plurality of strips of insulating material supported on said photoconductor and one adjacent to each of said color filter strips and the signal strip contiguous thereto.

15. A television pickup tube comprising an electron gun for producing an electron beam, a target in the path of said beam and comprising a transparent support member, a plurality of sets of signal output electrodes spaced apart on one surface of said support member, each of said sets including a signal strip, a color filter strip, an opaque insulator strip and a second signal strip continguously arranged and in that order, a photoconductor spanning said sets and the exposed surface of said support member therebetween, the portions of said photoconductive material over said opaque strips comprising a substantially fixed resistance, the portions of said photoconductive material over said color filter strips comprising a variable resistance, the junctions between a fixed resistance and a variable resistance being directly exposed to said electron beam, and a plurality of insulating strips each supported on said photoconductor adjacent to a color filter and the contiguous signal strip.

16. A target for a television pickup tube comprising a support member, a plurality of sets of signal output electrodes spaced apart on said support member, each 45 of said sets including a conductive color filter strip and an opaque conductive strip, the strips in each of said sets being spaced apart, a photoconductor covering said sets and the exposed areas of said support member therebetween, and a plurality of conductive tabs each supported on said photoconductor adjacent to one of said sets.

17. A television camera tube comprising an electron

gun for producing an electron beam, a target in the path of said beam and comprising a transparent support member, a plurality of sets of signal output electrodes spaced apart on one surface of said support member, and each of said sets comprising a layered unit of a color filter strip, a signal strip, a photoconductive strip, a semi-conducting strip, a narrow semi-conducting strip, and a conducting strip in that order each of said photoconductive strips comprising a variable resistance, each of said narrow semi-conducting strips comprising a substantially fixed resistance, and each of said semi-conducting strips comprising a portion of a direct current path between said electron gun and a junction between a fixed resistance and a variable resistance.

18. A television pickup tube comprising an electron gun for producing an electron beam, a target in the path of said beam and comprising a transparent support member, a plurality of pairs of conducting strips spaced apart on one surface of said support member, each of said pairs including one transparent strip and one opaque strip, a photoconductor spanning said pairs and the exposed areas of said support member therebetween, the portion of said photoconductor over each of said opaque strips comprising a substantially fixed resistance, the portion of said photoconductor over each of said trans-25parent strips comprising a variable resistance a sheet of semi-conductive material on said photoconductor and said sheet of semi-conductive material comprising a portion of a direct current path between said electron gun 30 and a junction between a fixed resistance and variable resistance.

19. A television camera tube comprising an electron gun for producing an electron beam, a target in the path of said beam and comprising a transparent insulating support member, a conductive layer on a surface of said support member, a photoconductive layer on the exposed surface of said conductive layer and comprising a variable resistance, a plurality of insulating strips spaced apart on said photoconductive layer and each comprising a fixed resistance, a plurality of conductive signal 40 strips each arranged on one of said insulating strips, a semi-conductive layer spanning said signal strips and the exposed areas of insulating strips and photoconductor therebetween, and said semi-conductive layer comprising a portion of a direct current path between said gun and 45 a junction between a fixed resistance and a variable resistance.

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